

The Impact of Solution Agglomeration on the Deposition of Self-Assembled Monolayers

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Self-assembled monolayers (SAMs) are commonly produced by immersing substrates in organic solutions containing trichlorosilane coupling agents. Unfortunately, such deposition solutions can also form alternate structures, including inverse micelles and lamellar phases. The formation of alternate phases is one reason for the sensitivity of SAM depositions to factors such as the water content of the deposition solvent. If such phases are present, the performance of thin films used for applications such as the minimization of friction and stiction in micromachines can be seriously compromised. Inverse micelle formation has been studied in detail for depositions involving 1H,1H,2H,2H-perfluorodecyltrichlorosilane (FDTS) in isooctane. Nuclear magnetic resonance experiments have been used to monitor the kinetics of hydrolysis and condensation reactions between water and FDTS. Light-scattering experiments show that there is a burst of nucleation at a critical concentration of hydrolyzed FDTS to form high concentrations of spherical agglomerates. Atomic force microscopy results show that the agglomerates then deposit on substrate surfaces. Deposition conditions leading to monolayer formation involve using deposition times that are short relative to the induction time for agglomeration. After deposition, inverse micelles can be converted into lamellar or monolayer structures with appropriate heat treatments if surface concentrations are relatively low.

Introduction

Self-assembled monolayers (SAMs) formed from organosilane coupling agents are used extensively in modifying the fundamental properties of surfaces for a wide range of technological applications. For example, such coupling agents provide one method of attaching hydrocarbon or fluorocarbon chains to silicon wafers to control friction and stiction in micromachines.¹ Unfortunately, coating processes involving silanes are known to be highly irreproducible, and film properties such as water contact angle can be highly variable.² Factors known to influence depositions include temperature,³ the solvent and its water content,⁴ coupling agent concentration, surface preparation,⁵ and even the container the substrates are coated in. Once layers are deposited, coating properties can continue to change. For example, exposures of SAMs to humid air can gradually degrade the hydrophobic character of the film, leading to increased adhesion with time.⁶

All these phenomena are influenced by the extent to which molecules of coupling agents interact with each other both in solution and on the substrate surface. In the classical description of assembly on a surface,⁷ chlorosilane coupling agents are assumed to have low affinity for the surface until they react with water to form hydroxysilanes (Figure 1). The $-OH$ groups in the hydroxysilanes can hydrogen bond to each other and to surface hydroxyl

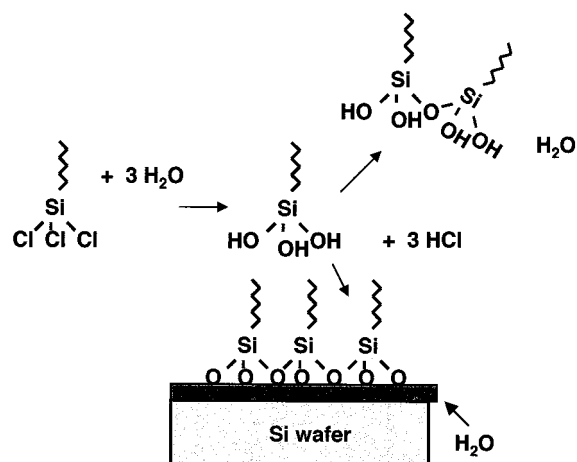


Figure 1. Schematic diagram illustrating reactions leading to the deposition of SAMs on wet Si substrates.

groups. Interactions between the hydrocarbon chains direct chain ordering to form a dense monolayer. Finally, a condensation reaction is assumed to occur in which hydroxyl groups react with each other to form Si–O–Si linkages within the monolayer and to the surface. The net result of this sequence would be the production of a dense, robust film that is highly cross-linked both laterally and to the Si substrate.

While simple and compelling, this picture glosses over several features of silane deposition processes that can lead to irreproducible results. First, deposition models tend to focus on hydrolysis and condensation on the substrate surface while ignoring the fact that the same reactions also occur in solution. If hydrolyzed molecules of the coupling agent form hydrogen-bonded (and eventually siloxane-bonded) networks on a surface, it is likely that such networks also form in solution as in the so-called “sol–gel” processing of silica.⁸ The fact that coupling agent solutions become cloudy with time shows that such aggregation does indeed occur. It is likely that the

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aggregation is not a random process but involves self-assembly phenomena to form micelles or other extended structures (e.g., lamellar, hexagonal, and cubic phases) similar to those observed for common oil-water-surfactant systems.²⁵ If these aggregates assemble and interact with the surface during film formation, monolayers will not be produced unless surface interactions are strong enough to restructure the aggregates.

A related problem is that even if monolayers are initially produced, it is possible that surface structures can rearrange to form alternate phases in response to changing environmental conditions unless cross-linking within the film is pronounced. Although NMR results for high-surface-area materials suggest that condensation can be extensive,⁹ other researchers report that the extent of condensation is negligible.¹⁰ Recent results on reversible phase changes in films of octadecyltrichlorosilane (ODTS) spread onto a thin water layer on silicon substrates suggest that the extent of condensation, even between adjacent molecules, is relatively low.¹¹ Individual molecules within the SAM appear to be mobile, indicating that headgroup interactions involve hydrogen bonding rather than the formation of covalent bonds. Molecular mobility may be critical during film formation but could lead to serious problems with regard to long-term film stability if condensation reactions do not lock the films into place before they have a chance to rearrange.

The purpose of this investigation is to examine structures produced in solution and on substrate surfaces for a specific thin-film deposition system consisting of 1H,1H,2H,2H-perfluorodecyltrichlorosilane (FDTS) dissolved in isooctane. The hydrocarbon chain of FDTS has 10 carbons, of which all but the two adjacent to the $-\text{SiCl}_3$ group are fluorinated to make the chains more hydrophobic. Such fluorocarbon chains are reported to have antistiction and antifricition properties superior to those exhibited by hydrocarbon chains.¹² Isooctane was investigated as the solvent to address environmental concerns (against aromatic and chlorinated solvents). Although effective antistiction coatings have been produced using FDTS-isooctane solutions, the existing coating process is known to be even harder to control than ODTS deposition. The goals of the work are to identify mechanisms for the development of film structures and to establish guidelines for selecting optimum processing conditions for fabricating high-quality films.

The focus of this work involves identifying mechanisms for the development of film structures and guidelines for optimizing film processing conditions to obtain free micromachined structures. The primary processing variables of interest involve the deposition solution. First, it is widely recognized that control of the water content is critical to the formation of dense silane monolayers. Higher water contents are expected to accelerate the rate of coupling agent hydrolysis both in solution and on the surface. However, the amount of water required for optimum films is open to debate. Some groups claim that discrete layers of water must be present on the immediate silica surface for SAMs to form,⁵ while other groups claim⁴ that water in the bulk solvent is required to produce good films. The amount of water required for the complete hydrolysis of a trichlorosilane is 3 times the moles of silane (3 mM for a standard 1 mM silane deposition solution). However, such high water contents could promote rapid hydrolysis and condensation in solution, precipitating the coupling agent before it has a chance to react with the surface. At the other extreme, the quantity of water required for hydrolysis of a complete self-assembled monolayer on silica (around 5 silane molecules per nm^2) is 7.5 water molecules/ nm^2 (as little as 2×10^{-7} M if initially dissolved in the solvent). However, maintaining water layers on the silica surface probably requires that the solvent be near or above the water saturation limit (otherwise, the surface water will dissolve into the solvent). For isooctane, the saturation water content is 2.3×10^{-3} M, which is similar to the concentration required for complete hydrolysis of the dissolved silanes. Some researchers claim⁴ that the best films are achieved at intermediate concentrations (1×10^{-4} M, or sufficient water to completely react with 7% of the chlorosilane molecules).

A second critical variable in coating solutions is the deposition solvent. The solvent system plays a major role in controlling the solubility and reactivity of both water and the coupling agent. The solubility limits for water in the primary solvents of this study are 2.5, 8, and 60 mM for isooctane, CCl_4 , and CHCl_3 , respectively. The same solvation effects that increase the water solubility are also expected to enhance the "solubility" of Si-OH groups in the hydrolyzed headgroup, to suppress the "solubility" of the fluorocarbon tails, and, thus, to influence the stability regimes of phases in the surfactant-solvent-water phase diagram. The distribution of water between the solution and the substrate surface is also influenced by the solvent. At a water content of 2.5×10^{-3} M, the driving force for water to leave isooctane and form either surface layers on substrates or solution aggregates such as inverse micelles should be much greater than it is in CHCl_3 . Conversely, the water layers on Si prior to processing would be expected to dissolve in a 2.5×10^{-3} M solution of water in CHCl_3 . If the best coatings are produced with the maximum surface water and the minimum bulk water concentrations (ensuring that hydrolysis is favored on the substrate rather than in solution), then isooctane should be the most effective solvent of the three in promoting monolayer formation. Finally, more polar solvents such as chloroform (CHCl_3) are expected to promote the kinetics of hydrolysis and condensation by stabilizing the polar intermediates involved in nucleophilic attack on tetrahedral Si centers. At identical water contents, reaction rates in CHCl_3 are expected to be more rapid than those in isooctane.

The role of water and the solvent in mediating film formation have been determined using a range of techniques that probe what is happening to the coupling agent

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in both the solution and the substrate surface. The kinetics of hydrolysis and condensation of FDTS in the solution phase have been determined using ^{17}O nuclear magnetic resonance (NMR) techniques to follow the solution concentrations of water and oxygen-containing products. Light-scattering methods have been used to determine whether such hydrolysis and condensation lead to the formation of FDTS aggregates in solution. In parallel, contact-angle and ellipsometry measurements have been used to determine the kinetics of film formation on Si substrates, while atomic force microscopy (AFM) has been used to image thin film structures. This combination of techniques has enabled us to identify the critical solution parameters that influence the processing, structures, and performance of FDTS thin films. The results show that solution aggregates can be incorporated into film structures, contributing to irreproducible film properties.

Experimental Section

Reagent-grade solvents, including isooctane, chloroform, and carbon tetrachloride, were utilized without further purification. The solvent water content was varied by saturating quantities of each solvent via equilibration with a layer of water or by drying the solvent with activated molecular sieves (4A zeolites). Intermediate water content was obtained by mixing appropriate quantities of the wet and dry solvents. The water content of each solvent was measured using a Karl Fisher titration system (Accumet KF Titrator 150, Fisher Scientific). The 1H,1H,2H,2H-perfluorodecyltrichlorosilane (Lancaster) was used without further purification. All FDTS was stored in a drybox prior to use. Additions of FDTS to solvents for either solution hydrolysis or Si wafer coating experiments were performed in a drybox. All experiments were conducted at room temperature.

^{17}O NMR spectra were obtained on a Bruker AMX-400 spectrometer operating at 54.3 MHz using a 5 mm probe. A Hahn spin-echo pulse sequence was used to reduce baseline distortions. The spectra were recorded with a 90° pulse width of 20 ms, a spin-echo time of 10 ms, and a repetition delay of 100 ms. The number of scans varied from 1000 to 4000. All spectra were externally referenced to H_2^{17}O (0 ppm). In a typical NMR experiment, H_2^{17}O (20% ^{17}O -enriched water from Isotec Inc.) was equilibrated with the desired solvent at the desired concentration for up to 1 day. At $t = 0$, the desired concentration (typically 1 mM) of the coupling agent was added to the solution in the NMR tube and rapidly mixed prior to introduction into the spectrometer. Spectra were collected at regular time intervals for periods up to several days. All oxygen-containing species could be detected down to concentrations of around 10^{-4} M.

The average radius of gyration of objects dispersed in the solution was obtained using the quasielastic light-scattering (QELS) equipment and the analysis methods described previously.¹³ In the quasielastic light-scattering experiments, the intensity $I(q)$ of light scattered at wave vector q was autocorrelated to obtain the homodyne correlation function $C(t) = \langle I(q,0) I(q,t) \rangle$. The dynamic structure factor $S(q,t)$ was obtained from the standard relation $S(q,t) = [C(t) - \langle I(q,0) I(q,\infty) \rangle]^{1/2}$. The data were analyzed assuming that the solutions contained monodisperse spheres for which the structure factor is given by $S(q,t) = S(q) \exp(-q^2 D t)$, where $S(q)$ is the static structure factor, $D = kT/6\pi\eta R$ is the translational diffusion coefficient, and R is the hydrodynamic radius. Data are presented in terms of the hydrodynamic radius, which (for spheres) is equal to $R_g/0.775$, where R_g is the radius of gyration. In a typical experiment, FDTS was added to the isooctane, and the mixture was quickly stirred, added to a syringe equipped with a $0.2 \mu\text{m}$ filter to remove particulates, and injected into 50 mL quartz cuvettes that were then inserted into the light-scattering system. Scattered-light intensity was typically collected at an angle of 90° to the incident laser beam as a function of time.

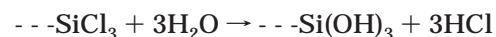
Silicon wafers were cut into $1 \text{ cm} \times 1 \text{ cm}$ squares. Prior to exposure to coating solutions, the wafers were cleaned using standard Piranha etching solutions to remove organic contaminants. In a typical coating experiment, $37 \mu\text{L}$ of FDTS was added to 50 mL of solvent to make a 1 mM FDTS solution. Solutions

were quickly stirred, and the Si square was immediately dipped into the solution for a specific time interval (ranging from 10 min to more than 2 h). Samples were removed from the coating solution, rinsed in plain solvent to remove excess coupling agent, and dried in the box. Some samples were then heat treated in a low-temperature oven or in a rapid thermal processing unit (AET Model Addax R4M) at temperatures of 150–400 $^\circ\text{C}$ and times ranging from 30 s to 5 min. Coating thicknesses were estimated using an ellipsometer (J. A. Woollam Co. Model WVASE32). Contact-angle measurements were performed using a static droplet video contact-angle system (Advanced Surface Technology, Inc. Model VCA 2500). Atomic force microscopy (AFM) topography measurements were obtained using a Digital Instruments Nanoscope IIIA in both tapping and contact modes.

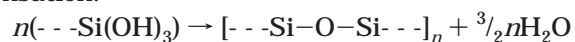
Results

^{17}O NMR Results—Kinetics of Hydrolysis and Condensation in Solution. To determine the optimum reaction conditions for attaching silane coupling agents to surfaces, we require information regarding how fast water reacts with the coupling agent in producing active species. The hydrolysis and condensation reactions relevant to activating and consuming trichlorosilane coupling agents in water are

hydrolysis:



condensation:



Nuclear magnetic resonance techniques can be used to monitor the concentrations of the reactants and products involved in both hydrolysis and condensation reactions in solution as functions of time. NMR-active nuclei that could be used in following reaction kinetics include ^{29}Si , ^{14}H , D , ^{17}O ,⁸ and (for FDTS) ^{19}F .¹⁵ In this investigation, the most definitive results were obtained using ^{17}O NMR. All ^{17}O in the initial solution is in the form of H_2^{17}O , which has a sharp resonance at around 0 ppm. As the water reacts with the coupling agent, new NMR peaks can be associated with Si–OH (near 25 ppm) and Si–O–Si (from 50 to 70 ppm). The rate at which the water signal disappears is used to determine the kinetics of hydrolysis, while the rate of appearance of the Si–O–Si peak can be used to establish the kinetics of condensation.

^{17}O NMR results have been obtained for water contents and coupling agent concentrations both ranging from 1 to 8 mM in isooctane and carbon tetrachloride. Representative NMR spectra in CCl_4 and isooctane (Figure 2) show that at short times the water concentration decreases and the Si–OH concentration increases, consistent with hydrolysis of the coupling agent (Figure 3). As expected, the initial hydrolysis rate increases with the initial FDTS and water concentrations. The specific rate law has not been determined, as the HCl liberated in the reaction (e.g., pH) is known to influence the reaction kinetics. However, for a 1 mM solution of FDTS in water-saturated (2.3 mM) isooctane, the first reaction stage has a pseudo-first-order rate constant of $3 \times 10^{-3} \text{ min}^{-1}$ (would be 50% complete in 90 min). At longer times, the Si–OH peak disappears, and the rate of water consumption is 10 times slower (pseudo-first-order rate constant of $4 \times 10^{-4} \text{ min}^{-1}$). The maximum Si–OH concentration in isooctane is around 0.6 mM (20% of the available FDTS, which has 3 equiv of Si–Cl bonds per molecule for a total of 3 mM). This maximum concentration is reached at fairly short reaction times (15–20 min for a 1 mM FDTS + 2.3 mM H_2O solution in isooctane). For more concentrated solutions (8 mM in both FDTS and water) in CCl_4 , the peak Si–OH concen-

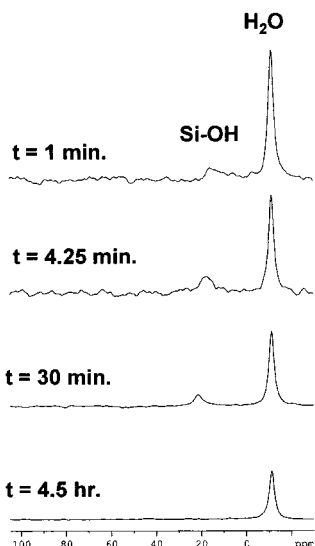


Figure 2. ^{17}O NMR spectra vs time for an 8 mM solution in FDTS and water in CCl_4 .

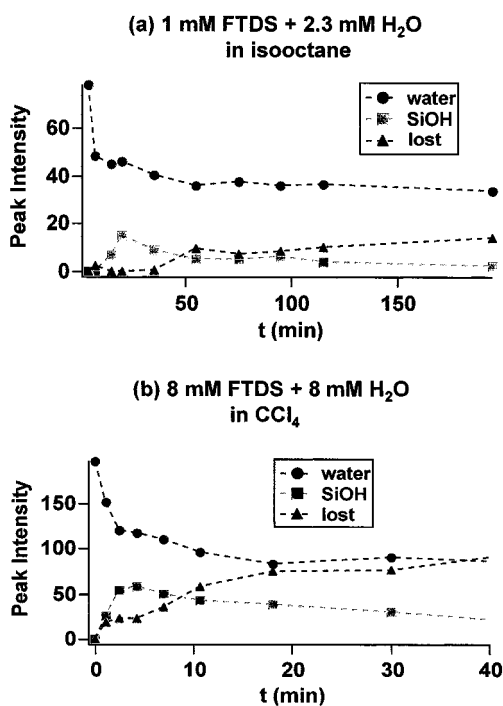


Figure 3. Relative species concentrations vs time in FDTS-coating solutions based on ^{17}O NMR peak intensities: (a) in 1 mM FDTS + 2.3 mM water in isooctane and (b) in a CCl_4 solution that is 8 mM in both FDTS and water.

tration is higher (2.3 mM) and is reached more quickly (in 4 min) than in the more dilute isooctane solution (Figure 3b). However, no new NMR peaks are observed to correspond to the formation of Si–O–Si linkages in either isooctane or CCl_4 . Instead, there is a decrease in the total ^{17}O NMR signal. The decrease (an 80% drop in 6 h for FDTS in CCl_4) is much more than can be accounted for on the basis of the formation of a monolayer of FDTS on the walls of the NMR tube (which would account for a loss of 0.3%). The loss in intensity means either that films containing hundreds of FDTS layers are being deposited or that objects are being formed in solution that are sufficiently large to broaden the NMR signals associated with them into the baseline.

The only solution investigated in which NMR spectra indicate the formation of Si–O–Si bonds has high

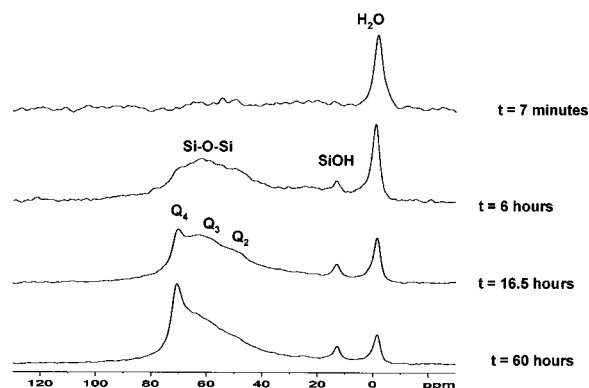


Figure 4. ^{17}O NMR spectra vs time for a 17 mM solution of both FDTS and water in CHCl_3 .

concentrations (1.7×10^{-2} M) of both water and FDTS in the polar solvent chloroform (CHCl_3) (Figure 4). In this solution, the rate constant for water consumption is 100 times greater than that seen in dilute isooctane (85% gone in 7 min for a pseudo-first-order rate constant of around 0.3 min^{-1}). However, in addition to the Si–OH signal near 25 ppm, significant NMR intensity is also observed at around 50 ppm, indicative of the formation of FDTS dimers (one bridging oxygen). At longer times, a broad series of peaks appears in the 50–75 ppm regime, indicative of soluble species containing two and even three Si–O–Si linkages per molecule. In potassium silicate solutions, such NMR peaks have been attributed to soluble species such as cyclic trimers and tetramers and prismatic hexamers.¹⁶ For FDTS, small cages are expected, as reported for silsequioxane solutions.¹⁷ Condensation is probably promoted in CHCl_3 and not in isooctane or CCl_4 due to the increased polarity of CHCl_3 , which promotes reactions involving nucleophilic attack. At longer times, the Si–OH peak does not drop toward zero. The constant value of 8×10^{-3} M reached for the Si–OH concentration from hydrolyzed FDTS monomers may represent the solubility limit in CHCl_3 . However, as seen in isooctane and CCl_4 , the total observable ^{17}O signal decreases with time (70% is gone in 7 min), indicative of the formation of large objects in solution or multilayer depositions.

Light-Scattering Results—Particle Dimensions and Kinetics of Particle Formation. While the NMR results provide information regarding the total fraction of FDTS that disappears from coating solutions, no information is provided regarding the nature of the missing material. We used light-scattering methods¹⁸ to determine if precipitates or micelles form and to obtain estimates of the average hydrodynamic radius and relative concentrations of objects in isooctane coating solutions as functions of time. Immediately after FDTS addition, light scattering from the solutions is negligible (Figure 5a), indicating that foreign particles are not at appreciable concentrations. For a 1 mM FDTS solution in isooctane containing 0.75 mM water, scattering continues to be low for 10–20 min after mixing. Then there is a sudden burst of nucleation. While induction times are variable (as expected for a nucleation process), they are comparable to the times at which Si–OH concentrations begin to drop in the ^{17}O NMR experiments. The first objects observed have a hydrodynamic radius of 75 nm (Figure 5b). These objects grow and stabilize at a radius of 130 nm over the next 10–15 min. The relative concentration of the objects as inferred from the total scattered intensity increases by a factor of 10 during this period. Objects continue to form even after further particle growth is negligible, consistent with the slow but continued hydrolysis indicated in the NMR

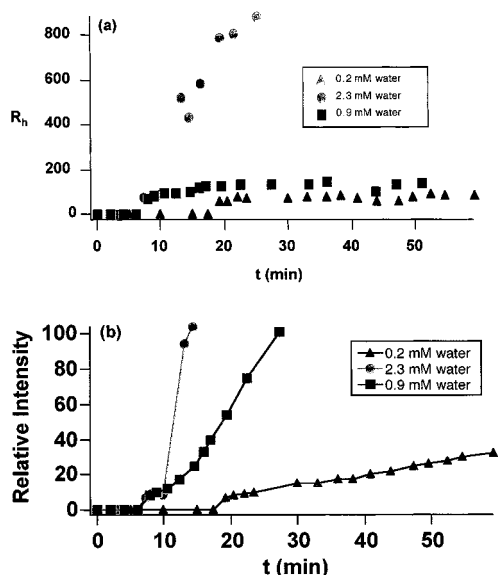


Figure 5. (a) Average hydrodynamic radius of objects in FDTS-isooctane solutions vs time and water content. (b) Scattered-light intensity vs time and water content for the same FDTS solutions.

experiments. Visual inspection of the solution in the cuvette indicates that the distribution of particles within the static solutions can be highly variable. Sometimes objects appear to nucleate within the center of the cuvette, while in other experiments, nucleation starts near the walls. Sometimes “banded” structures are observed which move in the cuvette with time. Such effects contribute to the observed scatter in both induction times and total scattered intensity as a function of time.

The induction time for nucleation decreases as the initial water content of the isooctane increases. The sensitivity of the induction time to water content is one reason for the irreproducible behavior of FDTS-coating solutions. The rate at which particles are produced also increases with water content. For 1 mM FDTS solutions in isooctane, the time required for the scattered intensity to saturate the detector (at 10^6 counts) decreases from 130 to 25 to 10 min as the initial water content is increased from 0.2 to 0.8 to 4.3 mM, respectively. Finally, the stable radius for the particles increases with water content from 95 to 130 to almost 800 nm for these solutions. All of these particles are large relative to the chain length of individual FDTS molecules (1.5 nm).

Contact-Angle Measurements—Deposition Rates for FDTS Films. Contact-angle measurements involving sessile drops of deionized water have been used to follow the kinetics of film formation on Si wafers immersed in FDTS solutions having compositions similar to those used in the NMR experiments. Water exhibits a relatively low contact angle (around 30°) on normal Si due to hydrogen bonding between the water and the silanols, which terminate the surface of the thermal oxide. As hydrophobic coupling agents are deposited on the surface, the contact angle increases with time. For a complete monolayer, the expected contact angle can be calculated using the Young equation:¹⁹

$$\gamma_{12} + \gamma_2 \cos \theta = \gamma_1$$

Calculated values for the contact angle of a complete monolayer are 110° and 115° for hydrocarbon and fluorocarbon SAMs, respectively. (Calculations are based on published values¹⁹ for the surface tension of water ($\gamma_2 =$

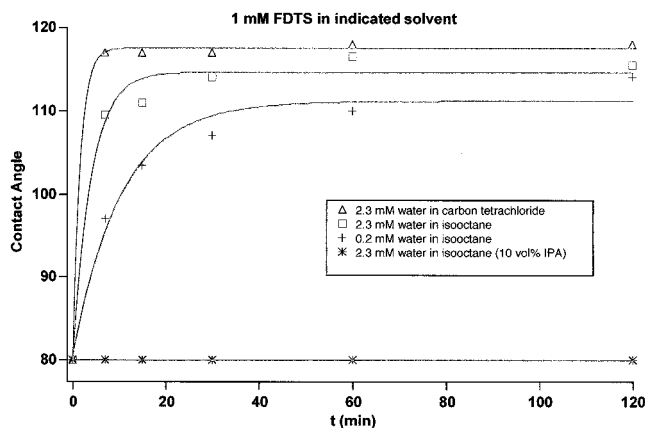


Figure 6. Contact angles for water on FDTS-coated Si substrates vs coating time and water content of 1 mM FDTS-coating solutions in wet and dry isooctane, wet isooctane containing 10 vol % 2-propanol, and wet CCl₄.

73 mJ/m^2), the surface energy of the monolayer ($\gamma_1 = 25$ and 19 mJ/m^2 for hydrocarbon and fluorocarbon chains, respectively), and the SAM–water interfacial energy ($\gamma_{12} = 50 \text{ mJ/m}^2$ for both hydrocarbons and fluorocarbons).) For surfaces that are partially covered by domains of coupling agents, the surface coverage can be inferred using the Cassie equation:²⁰

$$\cos \theta = f_1 \cos \theta_1 + f_2 \cos \theta_2$$

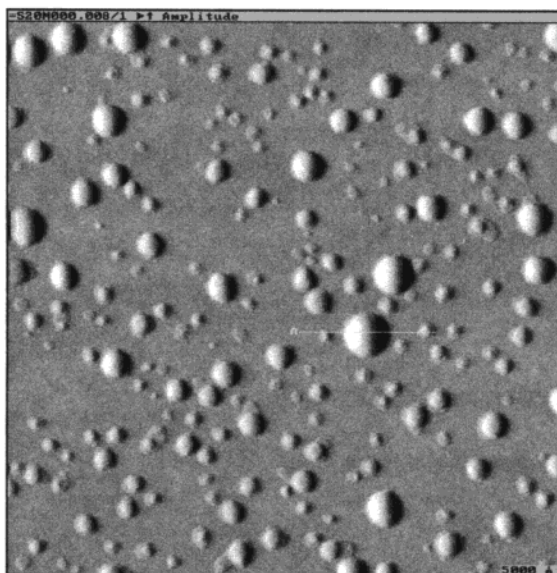
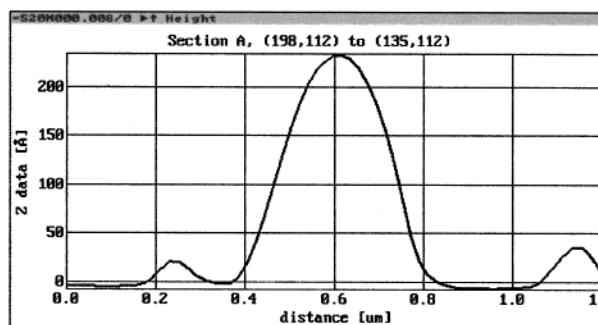
where f_1 is the fractional area of the surface covered by the monolayer, f_2 represents the uncovered surface, and θ_1 and θ_2 represent the contact angles for “pure” monolayer and uncovered surfaces, respectively (see ref 20 for a more rigorous treatment of contact angles on the two component surfaces).

Typical contact-angle results for Si substrates immersed in 1 mM solutions of FDTS in isooctane and CCl₄ are shown in Figure 6. Deposition kinetics mirror the kinetics of FDTS hydrolysis in solution. For isooctane solutions containing 2-propanol (a solvent used in rinsing micromachined parts in a typical release cycle), no FDTS coatings are produced. This is because alcohols react with Si–Cl bonds to form Si–OR groups that interfere with Si–OH and monolayer formation. For all other solutions, the contact angle and inferred FDTS coverage increase rapidly at first. The deposition rate increases with solvent water content. Once contact angles approach those expected for the completed monolayer (115°), the contact angle increases at a much slower rate. Times required to reach contact angles of 115° are comparable to those required to achieve the maximum Si–OH concentration in solution (2 h, 30 min, and <7 min for 0.17 mM H₂O in isooctane, 2.3 mM H₂O in isooctane, and 2.3 mM H₂O in CCl₄, respectively).

For most coating solutions, the observed contact angle continues to increase to values approaching 120° . In some instances, contact angles as high as 140° have been observed. Contact angles in excess of 115° are not indicative of continued packing of FTDS into the monolayer but are associated with a roughening of the surface (see AFM results below). The ratio (r) of the actual surface area relative to the geometric surface area can be estimated using the modified Young’s equation:²¹

$$\cos \theta_r = r \cos \theta$$

where θ_r is the apparent contact angle and θ is the inherent contact angle for the material at the surface ($\theta = 115^\circ$ for FTDS). On the basis of a contact angle of 140° , the surface

(a) Tapping Mode AFM Image**(b) AFM Line Scan**

**1 mM FTDS + 0.4 mM H₂O in isooctane
Deposition time = 1 hour**

Figure 7. (a) Tapping-mode AFM image (size = 5 μm \times 5 μm) of Si wafer after immersion in FTDS–isooctane solution for times exceeding the induction time for solution aggregation. (b) Line scan in AFM image across the circular object indicated in Figure 8a.

area increases by as much as a factor of around 1.8. Such increases in surface roughness are only apparent at times exceeding the nucleation time for the formation of objects in solution as seen via light scattering.

Atomic Force Microscopy—Morphologies of FTDS Coatings on Silicon Substrates. We used atomic force microscopy (AFM) to determine if the roughening of the surface indicated by contact-angle measurements is related to the adsorption of the objects detected in solution via light scattering. For the AFM studies, silicon substrates were immersed in FTDS-coating solutions for specific times after mixing and were examined after drying in air. Samples immersed for short times in fresh FTDS solutions exhibited surface morphologies identical to uncoated Si substrates (flat regions in Figure 7a). Although no coating is visible, ellipsometry measurements indicate that FTDS is being deposited during this initial coating stage. However, the apparent thickness of the coating stabilizes at 0.3–0.5 nm rather than at the 1.5 nm value expected for a well-organized FTDS coating having the fluorocarbon chains tightly packed and oriented perpendicular to the surface. The ellipsometry results are consistent with the deposition of chains in an “amorphous” phase in which the chains are lying flat on the surface with random orientations and lower packing densities than in a well-organized self-assembled monolayer.²² For hydrocarbon chains, such films are typically observed when the hydrocarbon chain length is less than 10 (FTDS has 10 carbons in the chain) or when deposition temperatures are above the transition temperature for ordering. On the basis of the rough correlation between the melting point and the transition temperature for ordering for hydrocarbon chains,²³ it is estimated that the ordering temperature for FTDS should be between 25 and 30 °C. Although variable-temperature studies were not conducted, it is likely that ordered monolayers can be produced from colder deposition solutions.

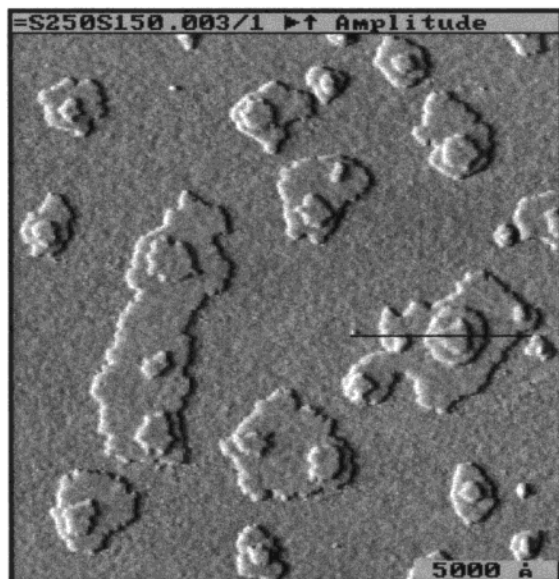
At times that roughly correspond to the induction times for nucleation of objects in solution, the surface morphology of the FTDS coatings undergoes a dramatic change (Figure 7a). Tapping-mode images show that FTDS is now in the

form of large circular objects. The diameter of the objects is normally slightly larger than twice the hydrodynamic radius of objects observed in the coating solution via light scattering. (For example, for isooctane solutions containing objects with a hydrodynamic radius of 130 nm, the diameter of the circular objects on the surface is around 300 nm.) Although these objects will subsequently be referred to as FTDS spheres, the objects are not spherical once deposited on a surface. AFM scans of the 300 nm diameter objects indicate a maximum thickness of around 25 nm (Figure 7b). Therefore, the objects resemble liquid droplets that sag and “wet” the FTDS-coated substrate. The number of droplets increases with time. In extreme cases, multilayers of the droplets have been observed, leading to film thicknesses in excess of 0.1 μm , as inferred by ellipsometry.

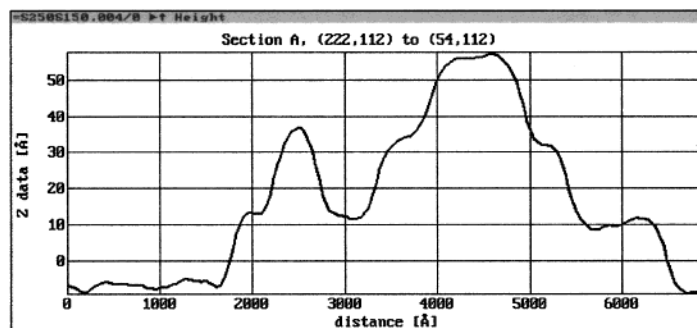
We have further probed the nature and stability of the FTDS by attempting to disturb the objects with the AFM tip (repeated scanning at high loads in contact mode) and by heating substrates coated with the spheres using rapid thermal processing (RTP) techniques. Repeated AFM scanning of the same region at high loads does not move the spheres relative to the substrate. Instead, the moving tip gradually smears out the spheres in the scanning direction. The spheres behave like viscous droplets containing mobile molecules rather than as rigid cross-linked solids.

When less than a monolayer of the spheres is present, heating the surface at 150 °C for less than 1 min is sufficient to completely change the surface morphology (Figure 8a). Such a heat treatment would be sufficient to vaporize isooctane and water from the surface (isooctane has a boiling point of 99 °C, similar to that of water). Now the surface is partially covered by multilayered structures rather than spheres. Each layer is atomically flat, with a layer thickness corresponding to the length of the FTDS chains (1.8 nm, Figure 8b). The multilayer domains are not spherical but irregularly shaped, often with straight side edges. Most commonly, two layers are apparent, although three layers are sometimes observed.

(a) tapping mode image



(b) line scan



**1 mM FDTS + 0.4 mM water
in isooctane
deposition time = 1 hour
RTP temperature = 150°C
RTP time = 50 seconds**

Figure 8. (a) Tapping-mode AFM image ($2\ \mu\text{m} \times 2\ \mu\text{m}$) of FDTS-coated Si wafer after RTP heat treatment at 150 °C for 1 min. Prior to heat treatment, the sample morphology was similar to that of the sample depicted in Figure 7a. (b) Line scan in AFM image of the object in Figure 8a, showing discrete steps equivalent to one chain length.

Friction measurements, which require tip-sample contact, were difficult to obtain because of the soft character of the structures. However, we have obtained one set of data suggesting that there is a strong friction contrast between successive layers. The immediate surface alternates between sticky and nonsticky behavior, consistent with the classical lamellar structure of surfactants (Figure 9). Such a structure has been reported previously for ODTS precipitates formed in water.²⁴ When the surface is terminated by fluorocarbon chains, tip-substrate interactions are weak, and adhesion and friction are low, as expected for FDTS monolayers. However, every other layer is oriented with the chains pointing down and the Si-(OH)₃ groups pointing up. The silanol-terminated surface is hydrophilic and can participate in extensive hydrogen bonding. It is expected to be quite sticky. The AFM friction results indicate how sensitive the surface adhesion can be to the orientation and local structures assumed by the FDTS molecules.

FDTS coatings containing spheres (deposited from isooctane) have been heated at temperatures of 250–400 °C using rapid thermal processing. At 250 °C, the films reorganize to form partial monolayers in less than 1 min (Figure 10a) rather than forming lamellar structures. The monolayer coverage is close to that expected if all the layers seen in the lamellar film were to be consolidated into a single layer (80–90% coverage is the maximum seen to date). Increasing the time or temperature of the heat treatment does not change the size or shape of the monolayer domains. However, above 300 °C, small pores nucleate and grow within the domains, and the surface coverage of FDTS drops (Figure 10b). It appears that the FDTS evaporates from films exposed to temperatures above 300 °C. The ease with which the lamellar-to-monolayer transition and high-temperature evaporation occur suggests that FDTS molecules are free to move relative to each other, at least in the early stages of heating. For films processed in isooctane, the ease of structural changes suggests that FDTS molecules deposited at room temperature interact with each other and with the surface

primarily via hydrogen bonding rather than by forming a highly cross-linked network of Si-O-Si bonds via condensation. This behavior is consistent with the NMR results suggesting that condensation is slow to negligible in isooctane solutions. Heat treatments can promote the condensation reaction and lock the films into place. For thick films initially containing multilayers of micelles, AFM images show that lamellar structures and even spheres can be retained after high-temperature ($T > 150\ \text{°C}$) RTP treatment. AFM images have been obtained for a few samples whose structures have been “frozen” via condensation as the spherical phase is in the process of transforming into the lamellar phase (Figure 11). Note that lamellar structures appear to be growing from the edges of the spheres, which are now “brittle” in appearance. These RTP results indicate that heat-treatment conditions must be selected with care to obtain desired surface morphologies.

Discussion

Structures of FDTS Agglomerates. Our results indicate that the FDTS spheres seen in the AFM images are the same objects seen in solution via light scattering based on their size and nucleation and growth kinetics. However, it is still not completely clear what the spheres are. The simplest spherical object to consider is an inverse micelle²⁵ (Figure 12a). Inverse micelles form when surfactants with hydrophilic headgroups and hydrophobic tails are in hydrophobic organic solvents with a low water content at concentrations exceeding the critical micelle concentration (cmc). The hydrocarbon tails on the micelle exterior interact with the solvent, while the hydrophilic headgroups line the interior and interact with an encapsulated water droplet. While the shape and nucleation behavior of the objects is consistent with inverse micelles, the size of the objects is too large to be consistent with the NMR results. If all the water left in a typical isooctane coating solution were encapsulated by all the hydrolyzed FDTS, the 9:1 molar ratio of H₂O:hydrolyzed FTDS

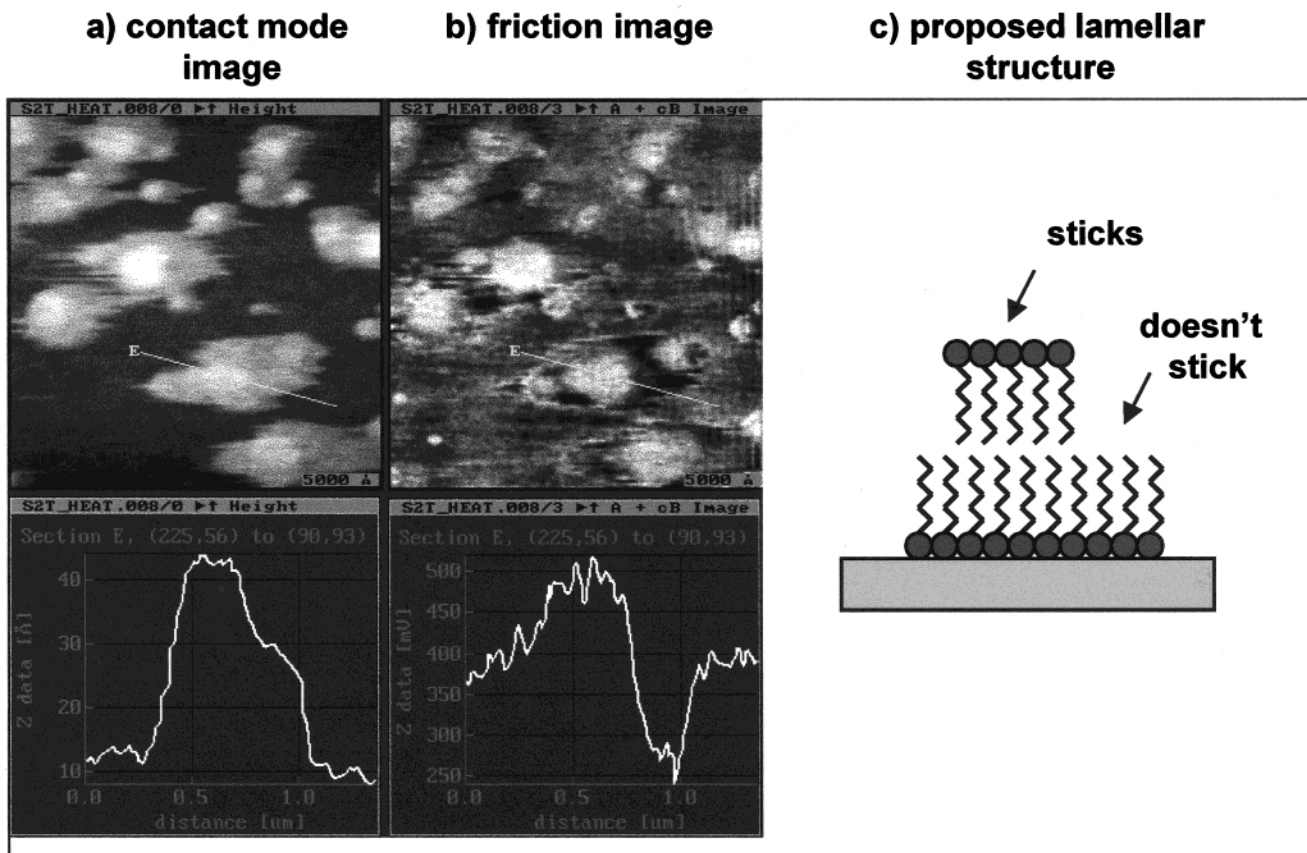
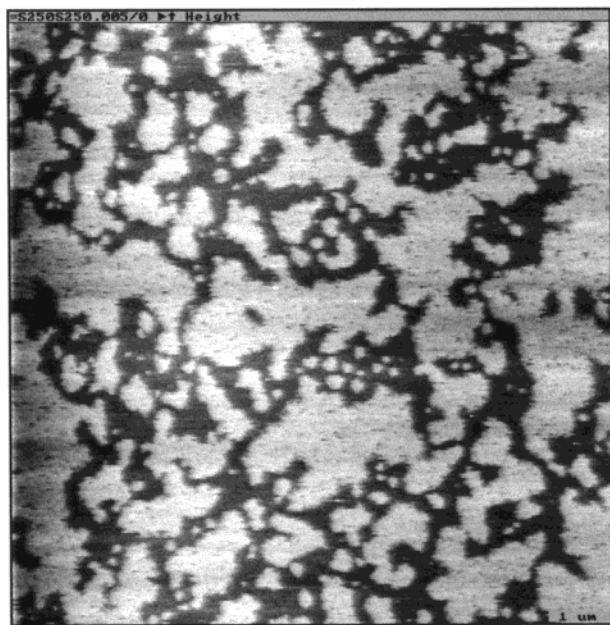


Figure 9. (a) Contact-mode AFM image (2 μm × 2 μm) of lamellar structure similar to the tapping-mode image in Figure 8a. (b) Friction image corresponding to the contact-mode image in Figure 9a. (c) Depiction of lamellar structure that would generate contrast between high and low friction between layers.

(a) monolayer film after 250°C, 5 min.



(b) porous monolayer after 350°C, 5 min.

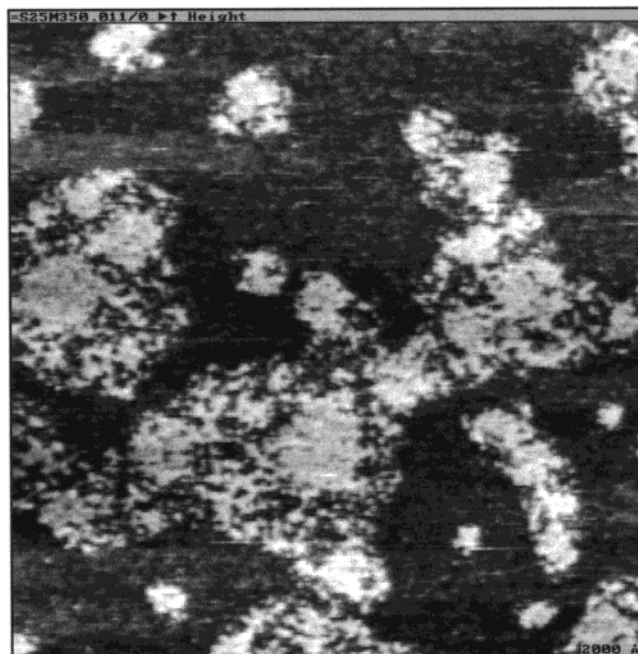


Figure 10. (a) Tapping-mode AFM image (10 μm × 10 μm) of monolayer formed on FDTS-coated Si wafer after RTP heat treatment of 250 °C for 5 min. (b) Tapping-mode AFM image (2 μm × 2 μm) of FTDS-coated Si wafer after heat treatment at 350 °C for 5 min, showing the appearance of porosity within the monolayer islands.

indicated by the NMR results would be consistent with an average micelle diameter of 7.4 nm (40 times smaller than the observed diameter of 300 nm).

It is possible that inverse micelles could aggregate to form 300 nm objects as in inverse microemulsions. Research on the behavior of fluorinated surfactants in

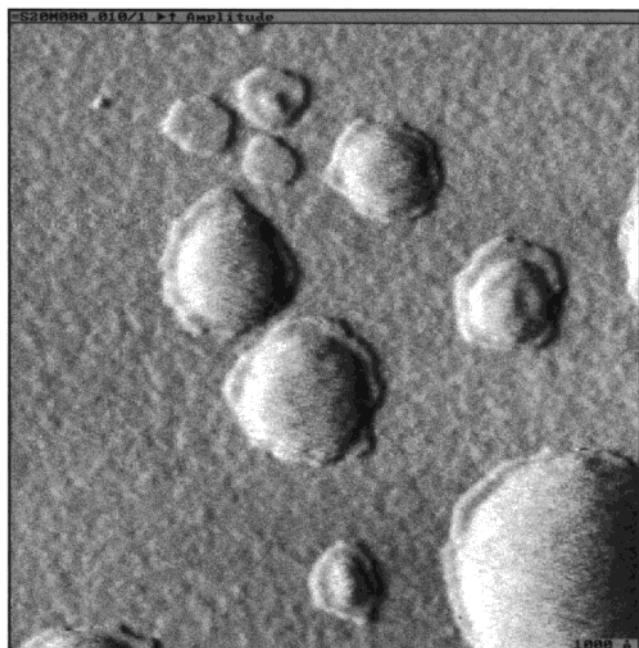


Figure 11. Tapping-mode AFM image ($1\ \mu\text{m} \times 1\ \mu\text{m}$) showing the transformation of spherical deposits into lamellar deposits.

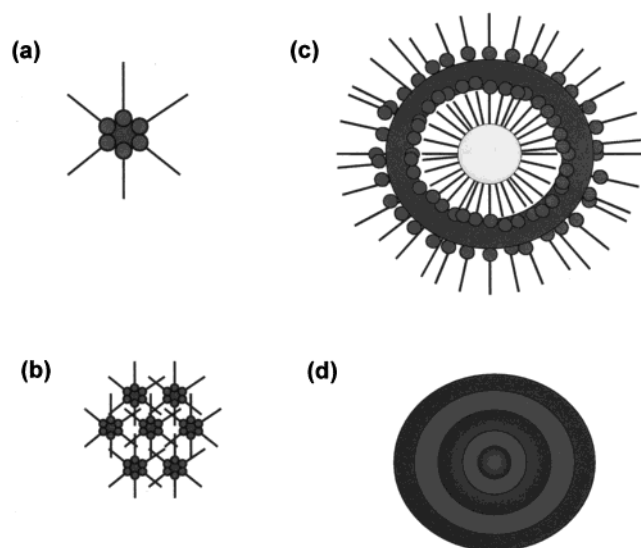


Figure 12. Representations of possible aggregate structures: (a) inverse micelles, (b) micelle aggregates, (c) inverse vesicles, and (d) nested vesicles.

water suggests that large spherical droplets of surfactant can form via micelle aggregation in a process resembling a liquid–liquid phase separation (Figure 12b). However, the driving force for such a phase separation should be less pronounced in isooctane than it is in water. The next simplest circular object to consider is an inverse vesicle (Figure 12c) consisting of a surfactant bilayer with the headgroups and a thin water layer in the layer interior. Isooctane is both inside and outside the vesicle whose interior and exterior walls are lined with hydrocarbon chains. In this structure, the vesicle size is independent of the H_2O :hydrolyzed FDTD ratio. Although the vesicle size cannot be predicted on the basis of solution chemistry, inverse vesicles as large as or larger than the objects here have been reported for surfactants dissolved in oil.²⁶ Objects containing nested bilayers (Figure 12d) (resembling an onion in cross section) have also been reported.²⁷

The AFM results obtained on films heated to $150\ ^\circ\text{C}$ (Figure 8) are most consistent with a transformation involving the rupture of inverse vesicle structures. After vesicle rupture and solvent evaporation, the skin of the vesicle might lie flat on the surface to form a largely bilayer structure whose lateral dimensions would be about twice that of the parent vesicle. However, the AFM results obtained on “transforming” films (Figure 11) appear to be more consistent with an inverse micelle aggregate structure for the spheres. On the surface, the aggregates could spread out to form droplets that are two to three micelles thick. Removal of the water could transform each micelle layer into a monolayer. Such a transformation would be expected to start on the edges of the spheres as observed rather than being an “explosive” event such as the rupture of a vesicle.

Regardless of which structures are actually present, the light-scattering and AFM results indicate that FDTD is capable of organizing into a wide range of aggregate structures similar to those seen for surfactants.²⁵ In a typical surfactant phase diagram, the dominant phase is controlled by the concentrations of both the surfactant and water in a given solvent. The phase diagram will be different depending on the specific coupling agent, the solvent, and the reaction temperature. Such parameters control the extent to which the headgroups and tails interact with each other and whether components are locked into place via condensation reactions. A further complication associated with solutions of silane coupling agents is that one of the active components in the diagram, the hydroxylated coupling agent, is being created as a function of time, while another component (the water) is being consumed. This means that the phases in solution are expected to evolve with time. Finally, a modified diagram will be required to describe the phases on the substrate surface, as interactions between the hydroxylated headgroup and the substrate must be included in addition to the interactions involving headgroups, tails, and solvent in the bulk solution. Given the range of structures that can form in solution and on surfaces, it is no wonder that researchers have had difficulty in defining appropriate processing conditions for producing monolayers in a reproducible fashion. It is also no surprise that different groups obtain different results with different combinations of solvents, solvent water contents, and coupling agents. While it was beyond the scope of this project to determine phase diagrams for FDTD–water–solvent systems, it appears that spherical agglomerates are the dominant structures in all solvents and at all water contents investigated once FDTD hydrolysis has occurred. For films deposited at room temperature, spherical agglomerates or monolayers are always seen. The lamellar phase has only been observed for samples which have seen a sufficient heat treatment to remove the bulk of the solvent and the water.

Processing and Performance Implications. Given the complexities associated with FDTD deposition solutions, it is important to establish guidelines that can be used to favor the formation of the desired self-assembled monolayers. The simplest method for obtaining a monolayer is to use fresh deposition solutions in which the concentration of the hydroxylated coupling agent has not yet reached the critical aggregation concentration. The induction time for aggregate formation depends on the coupling agent, the solvent, and the solvent water content.

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For FDTS in isoctane, induction times range from a few minutes to more than 2 h, depending on whether the solvent is saturated with water (at 2.3 mM) or dry (<0.2 mM). Previous studies have shown that pretreatment of Si substrates can improve coating reproducibility by promoting hydrolysis on the surface. The use of a "wet" substrate in a "dry" solvent is expected to yield the best results. However, water layers on "wet" substrates will dissolve in "dry" solvents, decreasing the surface water content and increasing the solvent water content until solution water concentrations reach the solubility limit. Care must be taken to keep processing times relatively short and to not coat too many substrates in the same coating solution. For 1 mM FDTS in isoctane, we recommend starting with dry solvent (<0.2 mM), using dry containers and fixtures, coating no more than twenty 4 in. wafers per 100 mL of coating solution, and removing all substrates from the solution in less than 1 h after the initial FDTS addition. (This will normally limit the use of the coating solution to one batch of wafers.)

Although extensive studies were not performed to determine the role of the solvent and the coupling agent on self-organization in solution, some trends can be predicted based on the limited NMR observations to date. At least for short chain coupling agents, the critical aggregation concentration tends to be higher in solvents that are more polar. This is because the hydroxylated headgroups have a higher effective solubility in polar solvents. Trends in the cmc should mirror the solubility of water in a given solvent ($\text{CHCl}_3 > \text{toluene} > \text{CCl}_4 > \text{isoctane}$). However, unless care is taken to dry the solvents, more water will be in solvents having a high cmc. In addition, at identical water contents, hydrolysis and condensation rates are faster in more polar solvents. This means that although the cmc is higher in CHCl_3 than it is in isoctane, the cmc may be reached sooner in CHCl_3 if the CHCl_3 is wet. On the other hand, if the CHCl_3 is scrupulously dried, it will be more effective at dissolving the thin water layer on substrate surfaces, which may inhibit monolayer formation.

Predicting the effect of the coupling agent on the processing window available for monolayer formation is also complex. In general, it appears that better results are obtained when the driving force for self-assembly in solution is driven more by the chains than by the hydrolyzed headgroup. Monolayer formation appears to be favored by increasing the chain length. (This is why ODTS precipitated in water assumes a lamellar rather than an inverse micelle structure.²⁴) Aggregation of the headgroups can be suppressed by replacing one or two of the chloro groups with methyl groups. Unfortunately, the presence of methyl groups can sterically interfere with monolayer formation, inhibiting the kinetics of film formation and producing films with low packing densities.²⁸ Chain solvation is clearly important and may contribute to the fact that 1 mM solutions of fluorinated coupling agents such as FDTS are more prone to aggregate in solution than comparable ODTS solutions even though both systems have comparable transition temperatures for chain ordering.

After deposition, changes in either temperature or humidity can influence the distribution of phases on the substrate. The AFM images presented here indicate that removal of water promotes transitions from droplets to lamellar structures to monolayers. Conversely, previous work has shown that exposing monolayers to humid environments can lead to restructuring to form spherical objects resembling those shown here.⁶ The restructuring of a monolayer will at least reduce the surface coverage of coupling agent, creating bare patches. Depending on what structures form, the surface can also end up being terminated by silanol groups rather than hydrocarbon chain. Both factors can lead to a deterioration of the antistiction or antifricition properties of the film. Thermal treatments that promote condensation reactions between silanol groups can lock surface structures into place, inhibiting surface reorganization. However, care must be taken to ensure that mild heating is performed to remove water and promote monolayer formation before the high-temperature cure for removing silanols is performed.

In summary, the aggregation of hydrolyzed silane coupling agents in solution can impact the quality of self-assembled monolayers. Irreproducible results in coating quality can often be attributed to whether aggregates are formed during the time interval in which substrates are exposed to the coating solution. (Microcantilever-release experiments performed on micromachined parts monitoring stiction indicate that release occurs for samples in which simple monolayers are present, while release is inhibited when FDTS aggregates are observed.) Factors that influence the induction time for aggregate formation include the solvent, its water content, and coupling agent concentrations. The time window available for producing quality coatings from a given coating solution can be maximized by scrupulously drying solvents prior to FDTS addition. Processing times can also be manipulated and controlled if the phase behavior of the coupling agent–water–solvent phase diagram is known. For thin coatings, heat treatments can sometimes restructure surface aggregates into lamellar or monolayer structures. Such heat treatments also promote condensation reactions that tend to lock film structures into place. A two-step heating procedure is recommended if monolayer formation is desired (heating at 100–150 °C to promote film restructuring, followed by a short treatment at 250–300 °C to promote condensation and cross-linking). The cross-linking step should also enhance long-term film stability.

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